PROCEEDINGS OF SPIE

AOPC 2019: Quantum Information Technology

Jianyu Wang Chaoyang Lu Sven Höfling Editors

7–9 July 2019 Beijing, China

Sponsored by Chinese Society for Optical Engineering (China)

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Organized by
Chinese Society for Optical Engineering (China)
Photoelectronic Technology Committee, Chinese Society of Astronautics (China)
Science and Technology on Low-light-level Night Vision Laboratory (China)
Science and Technology on Electro-Optical Information Security Control Laboratory (China)
Academy of Opto-Electronics of Electronics Technology of China (China)
Infrared and Laser Engineering (China)

Published by SPIE

Volume 11339

Proceedings of SPIE 0277-786X, V. 11339

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

AOPC 2019: Quantum Information Technology, edited by Jianyu Wang, Chaoyang Lu, Sven Höfling, Proc. of SPIE Vol. 11339, 1133901 · © 2019 SPIE CCC code: 0277-786X/19/\$21 · doi: 10.1117/12.2564868

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Please use the following format to cite material from these proceedings:

Author(s), "Title of Paper," in AOPC 2019: Quantum Information Technology, edited by Jianyu Wang, Chaoyang Lu, Sven Höfling, Proceedings of SPIE Vol. 11339 (SPIE, Bellingham, WA, 2019) Seven-digit Article CID Number.

ISSN: 0277-786X

ISSN: 1996-756X (electronic)

ISBN: 9781510634503

ISBN: 9781510634510 (electronic)

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445 SPIE.org

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Introduction

AOPC 2019, the annual conference of Chinese Society of Optical Engineering (CSOE), was one of the largest academic and industrialization activities in the field of optical and optoelectronic technology in China. The Organizing Committee intended to build a potential platform together with academic exchanges, industry exhibitions, and cooperation negotiations in one. There were 11 technical conferences and 38 conference sessions, and we sincerely hope that the research and development of optoelectronic technology were promoted, and that international cooperation in industry and in the optical and optoelectronic fields were enhanced.

AOPC 2019 was sponsored by SPIE and the Chinese Society for Optical Engineering; the Optical Society of Korea (OSK), Optics and Photonics Society of Singapore (OPSS), European Optical Society (EOS), Optical Society of Japan (OSJ) were the technical co-sponsors. There were also 48 Cooperative Organizations that supported the conference.

We received over 930 total contributions from more than 15 countries, including United States, United Kingdom, Germany, France, Spain, Australia, Canada, Mexico, Brazil, Japan, Republic of Korea, Thailand, Singapore, Russian Federation, China, and so on. There were 554 contributions published in SPIE Proceedings.

After careful discussion, we suggested four keynote speeches which were presented by famous scientists from Germany, Australia, Japan, and China. There were 110 excellent invited talks, 45 of them are from overseas, their inclusion represented a first-class level in the field of optics and photonics technology. On behalf of the Organizing Committee of AOPC, I express thanks to all the invited speakers and authors for their contributions and supports to the conference.

Finally, on behalf of the Chairmen and the Organizing Committee of AOPC, I would like to heartily thank our sponsors and Cooperating Organizations for all they have done for the conference, to all of the participants and friends for their interests and efforts in helping us to make the conference success. Also, thanks to the Program Committee for their effective work and valuable advice; especially the AOPC 2019 Secretariat and SPIE for their tireless effort and outstanding services in preparing the conference and publishing the Proceedings.

We are glad that AOPC 2019 had great success! Hope to see you next year!

Guofan Jin